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## COMMENT

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### Reply to the 'Comment on "Investigations on HONO formation from photolysis of adsorbed HNO<sub>3</sub> on quartz glass surfaces'" by M. N. Sullivan, L. T. Chu and L. Zhu, *Phys. Chem. Chem. Phys.*, 2018, 20, DOI: 10.1039/C8CP04497J

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In their comment to our recent paper about low HONO and NO<sub>2</sub> formation by photolysis of adsorbed HNO<sub>3</sub> Sullivan *et al.* confirmed their former results of HNO<sub>3</sub> adsorption on silica under dry conditions using a quartz crystal microbalance. The authors concluded that the differences between their results and our conclusions are caused by the different experimental conditions, *i.e.* adsorption under very dry conditions compared to our experiments at 50% r.h. While we agree that adsorption of the highly water soluble HNO<sub>3</sub> will strongly depend on humidity, there is still the conflict in the photolysis frequency of adsorbed HNO<sub>3</sub> under atmospheric conditions to which the authors referred in their previous publications (see their atmospheric implication sections) and to which also our paper refers. If their results on both the adsorption cross sections of HNO<sub>3</sub> (two to three orders of magnitude larger compared to the gas phase) and the quantum yield for NO<sub>2</sub> formation (close to unity) are applicable under conditions prevailing in the atmosphere, then the photolytic lifetime of HNO<sub>3</sub> on surfaces would be only ~5 min for atmospheric solar flux (0° SZA), which is highly unlikely.

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In our previous paper<sup>1</sup> we studied the photolysis of HNO<sub>3</sub> adsorbed on quartz and Pyrex surfaces under conditions close to the atmosphere (actinic flux, HNO3 concentration, and humidity) and observed very low values of  $J(HNO_3 \rightarrow NO_2)$ and low secondary heterogeneous formation of HONO, which were based on well quantified levels of adsorbed HNO<sub>3</sub> (ion chromatography analysis) and gas phase HONO and NO<sub>2</sub> concentrations (LOPAP techniques). Since the spectral actinic flux was also quantified in our study by a calibrated spectroradiometer, we used the absorption cross sections of adsorbed HNO3 published by the group of L. Zhu<sup>2,3</sup> to calculate an average quantum yield of adsorbed HNO3 for NO2 formation of  $\phi(\text{HNO}_3 \rightarrow \text{NO}_2) = (3.4 \pm 2.6) \times 10^{-4}$ , see eqn (4).<sup>1</sup> This value is orders of magnitude lower compared to the studies of Zhu et al.4 and Abida et al.5 and the present comment by Sullivan *et al.*<sup>6</sup> In these studies, quantum yields near unity were observed in excimer laser photolysis experiments at 308 and 351 nm, which cover the same spectral range as we used in our study. If both quantities are applied, the photolytic lifetime of  $HNO_3$  adsorbed on silica surfaces would be only ~5 min for

atmospheric spectral actinic fluxes (0° SZA), which is highly unlikely. Accordingly, we tried to explain this conflicting data either by overestimated absorption cross sections (by underestimated levels of adsorbed HNO<sub>3</sub><sup>2,3</sup>) and/or overestimated quantum yields (by using excimer laser photolysis experiments<sup>4,5</sup>). In our previous paper<sup>1</sup> we left both explanations open, but finally used the high cross sections to calculate our low quantum yield, which rely on the measured adsorption isotherms.<sup>2,3</sup>

In their comment, Sullivan et al.<sup>6</sup> now conclusively showed by guartz crystal microbalance measurements that these adsorption isotherms are valid, resulting in monolayer coverage ( $\sim 10^{14}$  cm<sup>-2</sup>) of adsorbed HNO3 under completely dry conditions at ca. 16 mTorr HNO<sub>3</sub> gas phase partial pressure ( $\sim 20$  ppm mixing ratio at 1 atm), while we obtained the same amount in the lower ppb range at 50% r.h. Although some of the differences may still be caused by the very different saturation times applied (2 min in Sullivan et al.;<sup>6</sup> overnight in our study<sup>1</sup>), the explanation by Sullivan et al.<sup>6</sup> is indeed reasonable, since HNO<sub>3</sub> adsorption strongly increases with increasing humidity. It is worth mentioning that we observed in former experiments<sup>7</sup> that low ppb levels of HNO<sub>3</sub> easily pass through PFA (perfluoroalkoxy alkane) and Teflon tubes in very dry conditions, while it takes  $\sim 2$  h until HNO<sub>3</sub> levels reach 90% of final values when passing through a 2 m long PFA tube (4 mm i.d.) at 1 l min<sup>-1</sup> and 50% r.h. This is

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explained by the extremely high solubility of HNO<sub>3</sub> in the adsorbed water layer at higher humidity. In addition, with respect to the comment by Sullivan *et al.*,<sup>6</sup> it is not surprising that HNO<sub>3</sub> does not form a physical monolayer on the surface at  $10^{14}$  HNO<sub>3</sub> cm<sup>-2</sup> in the presence of several layers of adsorbed water at 50% r.h., where it will be present as a mixed HNO<sub>3</sub>/H<sub>2</sub>O phase. Since we quantified the amount of adsorbed HNO<sub>3</sub> in our previous study (see *e.g.* Fig. 5),<sup>1</sup> the used term "monolayer" clearly refers to a formal monolayer ignoring the unknown amount of co-adsorbed water. The same holds for the four (formal) monolayers of adsorbed H<sub>2</sub>O at 50% r.h. mentioned in Sullivan *et al.*,<sup>6</sup> which is also strictly not correct (see island adsorption of H<sub>2</sub>O<sup>8</sup>).

However, besides this somewhat academic discussion, for the main question, *i.e.* the photolysis frequency of HNO<sub>3</sub> and the resulting NO<sub>2</sub>/HONO formation, it is completely unimportant whether the  $10^{14}$  HNO<sub>3</sub> cm<sup>-2</sup> are adsorbed as a pure (hypothetical) monolayer or in a mixed HNO<sub>3</sub>/H<sub>2</sub>O phase (reality). For both situations the UV light irradiates all HNO<sub>3</sub> molecules. The photolysis frequency is by definition independent of the amount of HNO<sub>3</sub> (first order kinetics) and can be simply calculated from the ratio of formed products divided by the amount of adsorbed HNO<sub>3</sub> (see *e.g.* eqn (2)<sup>1</sup>), which were both directly measured in our study.

Since we performed our experiments under typical atmospheric conditions with respect to HNO<sub>3</sub> concentration, humidity and actinic flux, we are still convinced that our atmospheric implications are correct, *i.e.* at typical atmospheric humidity either the published high absorption cross sections of adsorbed HNO3 or the near unity quantum yields for its photolysis are not valid. In contrast, we cannot draw this conclusion for completely dry conditions under which the former studies<sup>2–6</sup> were performed. However, these studies should then not be extrapolated to the atmosphere (e.g. for the discussion on potential "renoxification" etc.), as the authors have done in their former publications.<sup>2-4,9</sup> Accordingly, photolysis of HNO3 adsorbed on non-reactive substrates - which is the topic of all papers cited above<sup>1-6,9</sup> - will be of minor importance in the atmosphere. However, as we already discussed in our previous paper,<sup>1</sup> the situation may change for HNO<sub>3</sub> adsorbed on complex substrates, e.g. on photosensitizer surfaces like humic acids - but that is a different story.

#### Conflicts of interest

There are no conflicts to declare.

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